

# Ferroelectric nanodomains in epitaxial GeTe thin films

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1	Ferroelectric nanodomains in epitaxial GeTe thin films
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11	(Dated: July 29, 2021)
	In the quest for materials for ferroelectrics-based spintronics with a large spin-orbit coupling, it is

essential to carefully control the ferroelectric domains structure, their spatial organization and the domain wall type. Here, we perform the growth of GeTe thin films on Si by molecular beam epitaxy in a large thickness range. We show that the volume fraction along with the size of the ferroelectric nanodomains can be controlled by finely adjusting the deposition thickness and temperature. We evidence the formation of  $71^{\circ}$ -type domain walls and in situ measurements during thermal cycling show the hysteretic appearance and decay of ferroelectric domains. In combination with a detailed analysis of the GeTe/Si interface, we demonstrate that the interfacial misfit dislocations formed during the growth plays a key role in the stability of the ferroelectric nanodomains.

PACS numbers: GeTe, ferroelectrics, domain wall

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#### INTRODUCTION I.

The epitaxial growth of thin films on single crystal sub-14 strates often leads to the development of strain fields. In 15 ferroelectrics, this provides an extra degree of freedom to 16 control their structure, ferroelectric transition tempera-17 ture, and related functionalities such as optical, dielectric 18 and piezoelectric responses [1-3]. The domain structure 19 plays a central role in the relaxation mechanisms, ow-20 ing to its strong dependence on tensile or compressive 21 <sup>22</sup> strain that is imposed by the substrate. Recently, strain engineering, by the selection of appropriate substrates, 23 24 and the control of charge screening in thin films and <sup>25</sup> superlattices has led to the discovery of new ferroelec-<sup>26</sup> tric phases showing exotic domain patterns and polarization textures. [4-8] Furthermore, strain relaxation in thick 27 films is often accompanied by the formation of ferroelas-28 tic domains and twin boundaries which can add further 29 functionalization [9] via self-organized domain patterns 30 [10-12].31

Among ferroelectrics a new class of materials with 32 high potentialities for spintronic applications has recently 33 been introduced as ferroelectric Rashba semiconductors 34 (FERSCs) [13 and 14]. Main results, obtained on  $\alpha$ -GeTe 35 thin films, have demonstrated that the reversal of the fer-36 37 38 consistent change in the spin chirality of the band struc- 72 determined by X-ray diffraction (three-dimensional recip-39 40 42 port up to room temperature has been detected [19]. All 76 of film thickness (10-1800 nm). Second harmonic gener-43 these advances pave the way for an all-electric spintronics 77 ation (SHG) microscopy combined to polarimetry anal-

46 remains unclear. Given the rhombohedral structure of <sup>47</sup> GeTe (R3m space group) and the existence of an electric 48 dipole in the (111) direction, eight possible polar domain 49 orientations are anticipated in this system. This was un-<sup>50</sup> ambiguously confirmed by the observation of herringbone <sup>51</sup> domain configurations in low-temperature  $\alpha$ -phase GeTe <sup>52</sup> crystals[20 and 21]. In the context of epitaxial (111)-53 oriented thin films a dominant self-poled state with a 54 polarization perpendicular to the surface has been evi-55 denced [15, 16, and 22]. However a few results [23 and 56 24 indicate that this is a simplified view and minority 57 incursions occur in thin films. In spite of the growing 58 interest in such ferroelectric Rashba semiconductors 25 <sup>59</sup> and 26], the detailed polar domain structure and spatial 60 organization has not been studied so far. These studies 61 are a prerequisite for the controlled switching of ferroelec-62 tric domains and the understanding of aging properties.

In this article we address the ferroelectric nanodomains 63 <sup>64</sup> organization of  $\alpha$ -GeTe thin films grown on Si(111), the <sup>65</sup> domain wall type, and the structure of the interface with 66 the substrate. As reported by Wang et al. [23], quasi- $\alpha$ -GeTe thin films can be grown on 68 Si(111) by molecular beam epitaxy using a pre-deposition 69 of 1 monolayer (ML) of Sb onto the substrate. It is an 70 ideal platform to study and control ferroelectric domains roelectric polarization under an electric field leads to a 71 as they are no more limited by grain boundaries. We have ture [15 and 16]. An effective spin-to-charge conversion 73 rocal space maps) in combination with low energy elechas also been demonstrated in a ferromagnetic-GeTe het- 74 tron microscopy (LEEM) the volume fraction of the fer-41 erostructure [17 and 18] and a nonreciprocal charge trans- 75 roelectric domains and the domains size in a large range 44 based on semiconducting materials. However the influ- 78 ysis reveal the local symmetry of these domains. Using 45 ence of the domain structure on these phenomena still 70 high resolution transmission electron microscopy (HR-

82 83 84 85 86 thermal expansion coefficients of both materials. 87

## **II. METHODS**

#### Sample preparation and GeTe thin film growth by 89 molecular beam epitaxy 90

88

Si(111) wafers (Siltronix; 550  $\mu$ m -thick;  $\rho$ =1-10  $\Omega$ cm) <sup>141</sup> 91 are first cleaned by acetone and ethanol rising before 92 introduction in ultra high vacuum (UHV,  $P < 10^{-7}$  Pa). <sub>142</sub> 93 95 97 surface reconstruction. Finally a deposition of 1 ML of Sb 146 dure (Dual beam FIB, FEI Helios 600 NanoLab), electron  $_{99}$  Si(111)- $\sqrt{3} \times \sqrt{3}$ -Sb reconstruction [27] that greatly im-  $_{148}$  thin films of GeTe on Si. The typical dimensions of the 100 103 (RHEED). All the deposition sources are effusion cells 153 a lateral resolution in the images of 1.25 nm. 104 from MBE-Komponenten. 105

#### LEEM and LEED surface characterization of 106 nanodomains 107

108 109 110 111 112 113 114 115 116 117 118 119 120 treatments were performed with temperature steps of  $10^{\circ}$ 121 C and waiting time of 30 min for stabilization. 122

#### X-ray diffraction and 3D reciprocal space maps 123

124 125 studied by X-ray diffraction at DiffAbs beamline (Syn- 177 [33]. We have thus developed a semi-analytic model for <sup>126</sup> chrotron SOLEIL). X-ray diffraction data have been mea-<sup>178</sup> the second harmonic polarimetry, combining the analytic 127 sured at 9.5 keV [0.13051 nm] and 16.9 keV [0.07336 nm]. 179 form of SHG with a vectorial modelling of the fundamen-

<sup>80</sup> TEM) we show that domain walls are only of 71°-type <sup>128</sup> The incident beam was focused on the sample surface <sup>81</sup> and that the GeTe/Si interface is stabilized by misfit dis-<sup>129</sup> to a size of  $250 \times 300 \ \mu m^2$ . The diffracted intensity locations that relax the large lattice parameter mismatch 130 was collected onto a 2D XPAD hybrid pixel detector. between both lattices. The reversible decay/growth of 131 Three-dimensional reciprocal space maps of the GeTe the ferroelectric nanodomains under annealing/cooling,  $132 222_c$  Bragg reflection were recorded by rocking the samas demonstrated by in situ LEEM, is attributed to the 133 ple by  $\pm 3^{\circ}$ . The typical step was about 0.01°. The data thermal stress induced by the large difference of linear 134 analysis consists of a flat field correction (of the possible 135 non-uniform response of the various pixels of the detec-136 tor) and then a conversion of the measured data from <sup>137</sup> the detector coordinates (pixel index) to diffraction an-<sup>138</sup> gles and thus to reciprocal space [28]. The 3D reciprocal 139 space map have been visualized finally using the Par-140 aView software.

## High-resolution transmission electron microscopy

HR-TEM investigations were performed with  $[1\overline{1}0]$ Then the substrates are degased at 1000 K during 12 h 143 zone axis at an accelerating voltage of 300 kV on a followed by repeated high temperature annealing (1500 144 JEOL JEM-3010 instrument with a spatial resolution K) during a few minutes in order to achieve a clean  $7 \times 7_{145}$  of 0.17 nm. Using focused ion beam preparation proceis performed on the Si(111) surface, forming the so-called 147 transparent ultra-thin sections were extracted from the proves the crystalline quality of the GeTe layer [23]. The  $_{149}$  electron transparent ultrathin sections are 15  $\mu$ m (length) GeTe thin films are grown by co-deposition of Ge (1100  $_{150} \times 5 \ \mu m$  (height)  $\times$  150–200 nm (thickness). GPA analy- $^{\circ}$ C) and Te (310  $^{\circ}$ C) in UHV at 275 $^{\circ}$ C and character- 151 sis was performed using the strain++ software applying ized by in situ reflection high energy electron diffraction  $_{152}$  a mask in reciprocal space of radius 0.8 nm<sup>-1</sup> producing

#### Second Harmonic Generation microscopy and 154 polarimetry analysis 155

Local second harmonic generation (SHG) measure-156 After growth the GeTe layers are transferred under 157 ments were conducted by means of an inverted optical UHV conditions and characterized by low energy electron 158 microscope. The fundamental wave is provided by a laser microscopy and low energy electron diffraction (LEEM 150 source emitting pulses of 100 fs duration at a repetition III, Elmitec GmbH). LEEM images were obtained in  $_{160}$  rate of 80 MHz, centered at a wavelength  $\lambda = 800$  nm. bright field mode at an incident energy of 26 eV where a 161 The sample was illuminated at normal incidence with local maximum of reflectivity occurs. At this energy the 162 a time-averaged power of 11 mW. The SHG images are reflected beams by the GeTe main domain and by the 163 obtained by scanning the sample with respect to the fotilted ferroelectric nanodomains are clearly separated in  $_{164}$  cused laser beam (objective  $\times 60, 0.85$  numerical aperture the focal plane. This allows to use either the medium con- 165 (NA)) using computer-controlled stepping motors. The trast aperture ( $\emptyset$ =30  $\mu$ m) to select all reflected beams or 166 output intensity was spectrally filtered and collected into the smallest contrast aperture ( $\emptyset$ =10  $\mu$ m) to select only 167 a photomultiplier. Polarimetry measurements are perthe reflected beam from the main domain. In situ LEEM 168 formed by recording the SHG images at different polarcharacterization of the domains evolution under thermal 169 izer and analyzer angles. In the case of a a medium fo-<sup>170</sup> cusing of the fundamental beam (0.70 NA, or smaller), a <sup>171</sup> scalar model using the analytic form of SHG is sufficient 172 to model the local polarimetry response at polar domains 173 [29], domain walls. [30-32] The use of a strong focusing 174 (0.85 NA) was necessary in this study to properly re-<sup>175</sup> solve the fine ferroelastic needles. In this case a vectorial The internal structure of GeTe thin films has been 170 treatment of the fundamental electric field is necessary

181 take also into account the mixed character of the stud- 236 [34 and 35] localized between ferroelastic a-nanodomain 182 183 184 185 ometries are presented in the Supplementary Note 1.

#### **RESULTS AND DISCUSSION** III. 187

In order to determine the structure of GeTe thin films 188 we have performed X-ray diffraction measurements. In 189 <sup>190</sup> Figure 1a, the iso-intensity surfaces of 3D reciprocal 191 space maps [34] of GeTe epitaxial thin films close to  $_{192}$  222<sub>c</sub> show four Bragg peaks (c stands for a pseudocution at low  $q_z$  can be assigned to a rhombohedral distor-tion of C. T. this for the 60 nm-thick GeTe film). tion of GeTe thin films stretched along the [111] growth 255 In addition to the rhombohedral distortion of the GeTe 197 198 199 200 stitute the vast majority of the thin film. In addition 256 cal symmetry and obtain the domain structure of non-201 202 203 <sup>204</sup> mains with a rhombohedral distortion along [111], [111] <sup>262</sup> GeTe film revealing stripe domains superimposed to a 205 206 208 respect to *c*-domains. 209

21 0 <sup>211</sup> fuse scattering around Bragg peaks provides some hints. <sup>209</sup> anism in SHG microscopy involving the focused laser <sup>212</sup> The minor Bragg peaks from the ferroelastic *a*-domains <sup>270</sup> (Gaussian) beam and the comparatively zero-size of the 213 214 215 218 219 220 221 222 223 224 films (Figure 1a-(i)), no additional X-ray diffuse scatter- 283 background showing out-of-plane polarization. 225 226 ing is measured indicating that ferroelastic *a*-domains are 284 As these ferroelastic nanodomains meet the surface 229 creases as shown by the increase of the ratio of the in- 287 (LEEM), with much higher resolution [36] (see Figure 230 tegrated intensities of minor Bragg peaks with respect 288 2b-c). The LEEM contrast in reflectivity mode (bright <sup>231</sup> to the major peak (Figure 1d). This gives rise also to a <sup>289</sup> field) shows bright and dark bands of intensity along <sup>232</sup> more complex diffuse scattering pattern originating from <sup>200</sup> the domains that reverse with the focusing conditions <sup>233</sup> the intersection area between ferroelastic *a*-domains of <sup>201</sup> of the microscope [37] (See supplementary materials S7). <sup>234</sup> different variants. Experimental signatures of these in-<sup>292</sup> This is typical feature of a ridge-and-valley morphology

180 tal focused electric field. The as derived fitting functions 235 tersections arise from diffuse scattering bridge patterns ied volumes (containing both a- and c-domain fractions) 237 Bragg peaks (Figure 1a-(iii)). The center of mass of the in both polarization plots (P-plots) and anisotropy plots 238 bridges indicates a 60° in-plane rotation of the strain, (simultaneous rotation of the polarization and analyzer). 239 a tilt angle of  $0.79^{\circ} \pm 0.05^{\circ}$  and an increased compres-The fitting functions related to both measurement ge- 240 sion of the (111) crystallographic planes by 4.37% in <sup>241</sup> the intersection area ( $q_z = 36.954 \text{ nm}^{-1} \pm 0.010 \text{ nm}^{-1}$ ). 242 Complementary X-ray diffraction measurements on non-<sup>243</sup> symmetric Bragg peaks show that all the domains have a rhombohedral structure (a=0.429 nm,  $\alpha$ =58.3°) and <sup>245</sup> that a single epitaxy exists with the Si substrate such 246 that  $\alpha$ -GeTe(111) ||Si(111) and  $\alpha$ -GeTe[110] ||Si[110] [23] 247 in pseudocubic coordinates. We can also estimate the 248 average azimuthal misorientation between grains to be 249  $0.7^{\circ}\pm0.2^{\circ}$  (Supplementary materials S1). Moreover, as <sup>250</sup> shown from the threefold symmetry of the  $222_c$  Bragg bic unit cell). The main Bragg peak is located along the axis perpendicular to the surface and is contored at  $^{251}$  peaks, the fraction of twinned grains is negligible in the  $^{252}$  layer. We estimate from the intensity of Bragg peaks  $q_z=35.408 \text{ nm}^{-1}\pm 0.010 \text{ nm}^{-1}$ . This Bragg peak posi-

axis. In the following the real space regions giving rise 256 unit cell, SHG microscopy combined to polarimetry analto this Bragg peak are referred as c-domains that con- 257 ysis is a highly suited method to investigate the lothree minor Bragg peaks are slightly angularly offset from 259 centrosymmetric ferroic materials. This method is apthis axis and localized at higher  $q_z = 36.733 \text{ nm}^{-1} \pm 0.010^{200}$  plied here to obtain the detailed domain structure of a nm<sup>-1</sup>. They can be assigned to minor ferroelastic do- <sup>261</sup> thick GeTe film. Figure 2a shows a SHG image of a thick and [111] (labelled *a*-domains). These distortions in- 203 background exhibiting a lower emission intensity. This duce a rotation of the (111) crystallographic planes by 264 image regroups all the domain contributions by combin- $1.36^{\circ} \pm 0.04^{\circ}$  (see Figure 1a-(iii)) and a slight compres- <sup>265</sup> ing three SHG images recorded at different sets of posion of the (111) inter-reticular distance of 3.74% with 200 larizer and analyser angles as explained in the Supple-<sup>267</sup> mentary Figure S2. The observation of the fine ferroe-To determine the domain boundary type, the X-ray dif- 200 lastic stripes is made possible by a convolution mechare clearly elongated along a precise direction in recip- 271 nano-object like in the SHG imaging of domain walls.[32] rocal space ( $37^{\circ} \pm 3^{\circ}$  with respect to  $q_z$  axis) and this 272 This artificial broadening allows for the observation of the extension is more pronounced for thinner films (60 nm- 273 nanoscale domains and the spectral analysis of the their thick GeTe thin film). This diffuse scattering indicates <sup>274</sup> local emission (see Supplementary Figure S3). The local the presence of well defined interfaces between  $a_{-}$  and  $c_{-}$  275 polarization is derived through the precise modeling of domains and can be assigned to 71°-type domain walls 276 the local SHG polarimetry (see methods) and the result due to finite size effect along the [110] direction (Figure 277 is displayed in the inset of Figure 2a. The GeTe(111) 1c). TEM cross-section views (Figure 1b) show indeed 276 films show three domain stripes oriented in-plane at 0° that ferroelastic *a*-domains are crossing the film with 279 and  $\pm 120^{\circ}$  with a polarization oriented along the width sharp and straight walls perpendicular to the [110] di-<sup>280</sup> of the stripes (see more details in Supplementary Fig-rection. These sharp interfaces are the only one observed <sup>281</sup> ures S4-S6). The local SHG polarimetry confirms also between the c-domains and a-domains. For the thinnest 282 the 3m point group symmetry of the film and reveals a

independent and do not intersect each other. For thicker 205 of the film they can be characterised by surface sensifilms, the volume fraction of ferroelastic a-domains in- 200 tive techniques, such as low energy electron microscopy

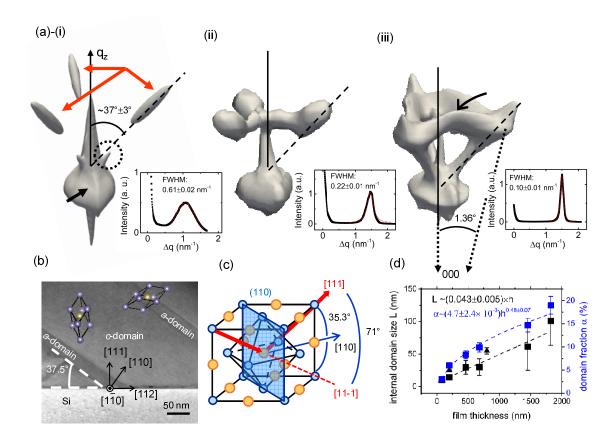


FIG. 1. (a)-(i) iso-intensity surface (2500 counts) of a 3D reciprocal space map around 222c Bragg peak of a 60 nm-thick GeTe thin film. Bragg peaks of main GeTe c-domains (black arrow) and ferroelastic a-nanodomains (red arrows). Minor ferroelastic Bragg peaks from the a-nanodomains are elongated at  $\sim 37^{\circ} \pm 3^{\circ}$  with respect to  $q_z$  axis (line profile along the dashed line in inset). Similar elongation of the diffuse scattering of GeTe c-domain (dotted circle) arising from the truncation of the c-domains by inclined a-domains (Babinet principle). (ii) and (iii) Same as (i) for a 200 nm (5000 counts) and 800 nm-thick (3000 counts) GeTe thin film. X-ray diffuse scattering bridge due to domains intersection (curved black arrow). (b) TEM cross-section of a 460 nm-thick GeTe thin film with medium resolution showing 2 a-nanodomains crossing the film ( $[1\overline{10}]$ zone axis). The rhombohedral unit cells indicates the elongation direction of the domains. (c) Scheme of the polarization (rhombohedral elongation) of the main GeTe c-domains along [111] and a secondary ferroelastic a-domain along  $[11\overline{1}]$  (in pseudocubic representation). (d) Domain size L and volume fraction  $\alpha$  of ferroelastic domains in GeTe thin films as function of film thickness deduced from the full width at half maximum of diffraction peaks of ferroelastic domains (triangle) and LEEM measurements (square).

294 295 296 297 298 299 300 301 302 beams increases as: 303

$$A = \frac{18}{\sqrt{3}} \frac{m}{\hbar^2} \pi \theta^2 E \tag{1}$$

304 <sup>305</sup> mass and  $\hbar$  is the reduced Planck constant. These do- <sup>322</sup>  $L \sim [0.043 \pm 0.005]h$  nm and reaches  $\sim 77$  nm for a 1825

203 and that indicates that the surface of the nanodomains 306 mains have a mean surface plane orientation that is tilted is tilted. Tilted surface patterns are characteristic fea-  $_{307}$  by  $1.37^{\circ} \pm 0.03^{\circ}$  in the  $\langle 11\overline{2} \rangle$  direction with respect to tures of ferroelastic domains. The mean tilt angle of the 308 the average surface plane. These tilted planes make the nanodomains has been quantitatively characterized by  $\mu$ - 309 same tilt angle as the (111) crystallographic planes of LEED [38]. The reflected beams from the three domains 310 the a-nanodomains obtained from the position of the mivariants  $(0, \pm 120^{\circ})$  are slightly off-specular with respect 31 nor Bragg peaks measured by X-ray diffraction. This to the main (0,0) reflected beam (Figure 2d and inset 312 unambiguously confirms the same ferroelastic origin of of Figure 2e) and the angular shift increases with the 313 the nanodomains at the surface and in the bulk of the incident electron energy E (Figure 2e). Quantitatively  $_{314}$  layer. From LEEM topographic measurements we have the triangle area A formed by the 3 equivalent reflected  $_{315}$  also quantified the evolution of the a-domain fraction 316  $\alpha$  as a function of the film thickness (Figure 1d). Be-317 low 30 nm, the *a*-domain fraction is null and the film 318 is therefore monodomain. Then it increases sub-linearly 319 [10 and 39] as  $\alpha \sim [4.7 \pm 2.4] \times 10^{-3} h^{0.48 \pm 0.07}$  (h is the  $_{320}$  film thickness in nm). The domain width L (Figure 1d) where  $\theta$  is the tilt angle ( $\theta \ll 1$ ), m is the electron 321 increases linearly over the entire range of thickness as

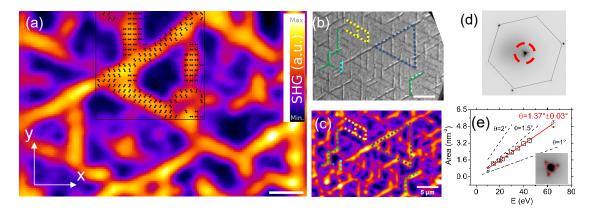


FIG. 2. (a) Isotropic second harmonic image revealing the domain structure of a 1825 nm-thick GeTe film. The black arrows indicate the local in-plane polarization orientation in the nanodomains as derived from pixel-by-pixel polarimetry analysis (see Supplementary Figure S3). The three different a-domain contributions (at  $-30^{\circ}$ ,  $30^{\circ}$  and  $90^{\circ}$  with respect to x axis) are superimposed to the background (dark purple) signal exhibiting out-of-plane polarisation (c-domain). The scale bar corresponds to 2  $\mu$ m. (b) LEEM image (bright field mode, incident electron energy: 26 eV) from the GeTe thin film (scale bar 5  $\mu$ m). (c) Same area visualized by spatially resolved SHG. Dashed lines in (b) and (c) are markers. (d)  $\mu$ -LEED pattern (20  $\mu$ m incident beam size) at 26 eV incident electron energy showing 4 reflected beams inside red dot circle: a main reflected beam and three minor beams originating from the nanodomains.(e) Area of the triangle formed by the three reflected beams (nanodomains) as function of the incident electron energy (from 8 to 65 eV). Linear fit (red line) and simulations for different tilt angles (dashed lines).

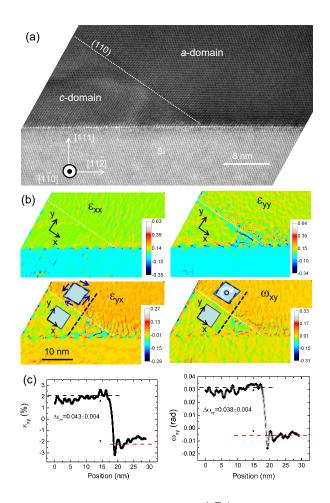
 $_{323}$  nm-thick GeTe film. These LEEM measurements are also  $_{352}$  notice that shear and rotation  $(2.2^{\circ})$  components com- $_{324}$  confirmed with the estimate of the *a*-nanodomain size  $_{353}$  pensate across the wall to have a coplanar (110) plane as  $_{325}$  from the full width at half maximum of the diffraction  $_{354}$  expected from mechanical compatibility of the interface peaks of the minor domains (insets in figure 1a). The do-355 between a- and c-domains (figure 3c) [46]. 326 327 main fraction and domain size results allow to evaluate 328 the effective period  $W = L/\alpha$  of the nanodomain pat- $_{329}$  tern. It reaches ~500 nm for a 1825 nm-thick GeTe film.  $_{357}$  switching processes are known to be highly sensitive to 330 Assuming in the mean strain approach [40–42] that:

$$W = \frac{\sqrt{h_0 h}}{2\xi \alpha \left(1 - \alpha\right)} \tag{2}$$

331 333 domain wall and interfacial stress with the substrate. 334

335 336 337 338 339 34 0 341 **34** 2 34 3 344 34 5 347 and perpendicular to the domain wall, we evidence that 380 pare the interfacial energy cost of both GeTe c-domains  $_{348}$  the diagonal components of the strain tensor,  $\epsilon_{xx}$  and  $_{381}$  and a-domains we can make some preliminary remarks.  $\epsilon_{4yy}$ , are equal on both sides of the wall whereas the pure  $\epsilon_{382}$  (i) The linear density of misfit dislocations is higher for 350 shear component  $\epsilon_{xy}$  and rotation field  $\omega_{xy}$  make a signif- 383 the *a*-domains (0.36 nm<sup>-1</sup>) than for the *c*-domains (0.24

Ferroelastic nanodomain formation and ferroelectric 358 the mechanical interactions with the substrate due to the 359 stress induced by the lattice mismatch. This effect may 360 be even more pronounced for epitaxial films. To address <sup>361</sup> the relaxation mechanisms prevailing in the formation of 362 these ferroelastic nanodomains we have characterized the 363 GeTe/Si interface with HR-TEM. Figure 4a shows the inwith  $\xi = 0.27$ , we have estimated a characteristic  $_{364}$  plane strain field ( $\epsilon_{xx}$ ) across the interface with x along length  $h_0 = 0.5 \pm 0.2$  nm of the nanodomain pattern  $_{365} \langle 11\overline{2} \rangle$ . The lattice parameter mismatch between the Si that balances the gain of elastic energy and the costs of  $_{366}$  substrate and the GeTe c-domain is locally  $8.2\pm0.2\%$  (fig-367 ure 4c). In the a-nanodomain  $\epsilon_{xx}$  is larger  $(12.2\pm0.2\%)$ The atomic scale characterization of the 71°-type do- 368 due to the nearly in-plane stretch of the rhombohedral main walls and a-domains has been addressed by high- 369 distortion. Considering the lattice mismatch the formaresolution transmission electron microscopy (HR-TEM 370 tion of a-domains is elastically unfavorable if the in-plane [43]). Figure 3a shows an area including the Si substrate, 371 lattice deformation is fixed by the Si substrate lattice a a-domain and a c-domain separated by a 71°-type do- 372 parameter. However the regular modulation of the inmain wall. Strain and rotation mapping of the crystalline  $_{373}$  plane strain component  $\epsilon_{xx}$  in GPA analysis shows that lattice of the GeTe layer in this area can be determined 374 this huge lattice parameter mismatch between the Si subby comparison with a reference (unstrained) region of 375 strate and GeTe thin film is relaxed via interfacial misfit the Si substrate far from the interface. This has been 376 dislocations with a period of 4.10 nm (resp. 2.77 nm) for carried out using the image-processing technique called 377 the c-domain (resp. a-domain). This result shows that the geometric phase analysis (GPA) [5, 44, and 45]. Con- 378 the dislocation-assisted stress release is the main relaxsidering that the x and y axes are respectively parallel 379 ation mechanism of the interface (see figure 4b). To com- $_{351}$  icant jump across the domain wall (figure 3b). One can  $_{384}$  nm<sup>-1</sup>). (ii) The in-plane lattice of the *a*-nanodomains



in (b)).

386 387 388 389 390 391 392 393

ing and cooling thermal treatments of GeTe thin films 424 tion. 394 (see Supplementary Figure S8 and corresponding movie). 395 Figure 5 shows that the ferroelastic nanodomains disap-397 pear at  $\sim 250^{\circ}$  C, *i.e.* slightly below the thin film growth 425 <sup>398</sup> temperature (275 ° C) and far below the Curie temper-399 ature ( $\sim 400^{\circ}$  C). Therefore we assume that a ferroelas- 426 In conclusion the domain structure of  $\alpha$ -GeTe thin

400 tic configuration with only a single domain occurs dur- 427 films epitaxially grown on Si(111) has been investigated. 401 ing GeTe growth with a unique rhombohedral distortion 428 By combining 3D reciprocal space mapping by X-ray

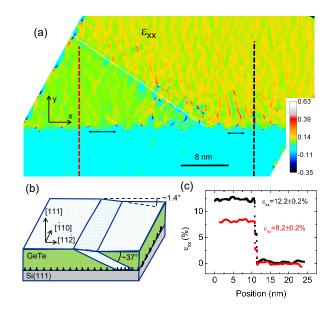


FIG. 4. (a) In-plane strain  $\epsilon_{xx}$  with x along the  $\langle 11\overline{2} \rangle$  GeTe/Si interface obtained from GPA analysis. The arrows at the GeTe/Si interface show the regular modulation of  $\epsilon_{xx}$ . (b) Model of the internal structure of GeTe thin films on Si(111). (c) Line profiles of in-plane strain  $\epsilon_{xx}$  across the interface (see dashed line in (a): dark (resp. red) line across the a-domain (resp. c-domain).

402 perpendicular to the film. When cooling, the ferroelas-403 tic *a*-nanodomains nucleate abruptly at  $210\pm10^{\circ}$  C. This <sup>404</sup> process is perfectly reproducible cycling the temperature. FIG. 3. (a) HR-TEM cross-section ( $\langle 1\bar{1}0 \rangle$  zone axis) of the 405 To explain this behaviour we infer that upon cooling a interfacial area between the Si substrate, a GeTe c-domain 406 thermal stress arises due to the different linear thermal and a *a*-nanodomain (domain wall: dotted white line) for a  $_{407}$  expansion coefficients of GeTe [47 and 48]  $\sim 31.9 \times 10^{-6}$ 460 nm-thick GeTe film. (b) In-plane  $\epsilon_{xx}$ , out-of-plane  $\epsilon_{yy}$ ,  $_{408}$  K<sup>-1</sup> and Si [49 and 50]  $\sim 3.5 \times 10^{-6}$  K<sup>-1</sup>. Assuming shear  $\epsilon_{xy}$  strain and rotation  $\omega_{xy}$  with x and y respectively  $\epsilon_{xy}$  that the interfacial misfit dislocations are not enough files of shear and rotation across the wall (see dark dashed-line 410 mobile to accommodate this change [51-54] and given 411 that GeTe lattice parameter should decrease faster than 412 that of Si substrate, a tensile in-plane strain occurs in 413 the GeTe layer. A very efficient way to macroscopically  $_{414}$  reduce this stress is to nucleate *a*-domains that expand  $_{355}$  is monoclinic whereas it is hexagonal for the GeTe c-  $_{415}$  locally the in-plane lattice parameter in the  $\langle 11\overline{2}\rangle$  didomains (as for the Si substrate). (iii) At last the inter- 410 rection. The three variants of the ferroelastic domains face plane of the *a*-nanodomains is expected to be tilted 417 provides a global isotropic relaxation. When the GeTe by 1.36° with respect to the Si surface plane (tilt angle 418 layer is annealed at a temperature close to the growth of (111) plane) whereas the main GeTe c-domain and Si 410 temperature it recovers its growth lattice parameter, and substrate are coplanar. Therefore the formation of the 420 therefore the a-nanodomains are elastically useless and a-nanodomains appears to be energetically unfavorable. 421 spontaneously decay (see Figure 5b-c). The hysteretic To address the metastability of these *a*-nanodomains <sup>422</sup> behaviour of the *a*-domains indicates also that a nuclewe have performed LEEM measurements during heat-

#### IV. CONCLUSION

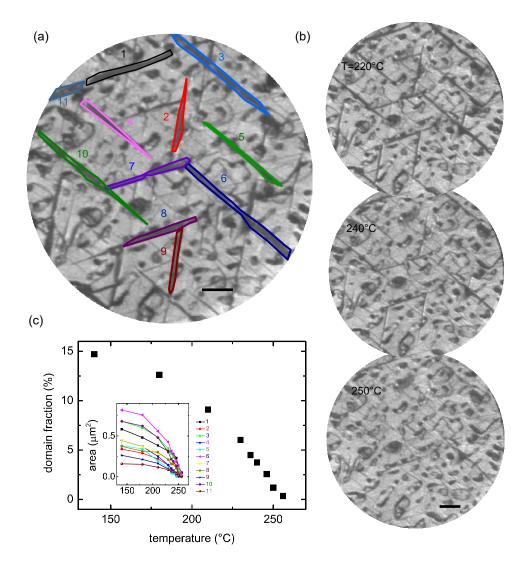


FIG. 5. (a) LEEM image (bright-field mode excluding the reflected beam from the nanodomains) of GeTe thin film (1455 nm) at 180° C. (b) Series of LEEM images at 220, 240 and 250° C. Scale bar 1 µm. (c) Temperature evolution of a-nanodomains fraction as function of temperature (inset: temperature evolution of some domains area shown in (a)). The dark contrast areas that have not a needle shape correspond to local depressions in the GeTe thin film.

429 diffraction, HR-TEM, SHG and LEEM we have quan- 446 not accommodate the relative change of lattice parame-430 tified the volume fraction and size of the nanodomains 447 ter. We believe that this detailed description of domain 431 as function of the film thickness. We have demonstrated 448 behavior as a function of temperature and film thickness 432 that domain walls are only of 71°-type and the interface 440 will serve as a playground for the control of ferroelec-433 434 that relaxes the large lattice parameter mismatch. Us- 451 new strategies to tune the Rashba effect by addressing ing in situ LEEM under cooling we have shown that the 452 the motion of domain walls. 435 ferroelectric *a*-nanodomains nucleate and grow whereas 436  $_{437}$  they decay under annealing and disappear at 250 °C.  $^{453}$ This result indicates that during GeTe growth at 275 454 438 °C, a single domain configuration occurs with a polar- 455 Library or from the author. 439 ization perpendicular to the film surface. We infer that 44 O this single domain state during growth is a key parameter that favors the high crystalline quality of the GeTe layer. 442 Then the driving force for the formation of the ferroelec-**44 3** 444 tric nanodomains at lower temperature is attributed to 445 the thermal stress as the dislocations are frozen and can-

with the Si substrate is stabilized by misfit dislocations 450 tric/ferroelastic nanodomains in GeTe and will motivate

### **Supporting Information**

Supporting Information is available from the Online

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